## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: T. HATTORI, et al.

Serial No.: 10/576,494

Filed: APRIL 20, 2006

For: POSITIVE PHOTOSENSITIVE RESIN COMPOSITION, METHOD

FOR FORMING PATTERN, AND ELECTRONIC PART

Group AU: 1795

Examiner: John S. Y. Chu

Confirm, No: 3727

## AMENDMENT

Mail Stop: AMEND – NO FEE Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450 March 12, 2008

Sir:

In response to the Office Action mailed December 12, 2007, please amend the above-identified application as listed below and as set forth on the following pages:

AMENDMENTS TO THE CLAIMS: and

REMARKS are included following the amendments.